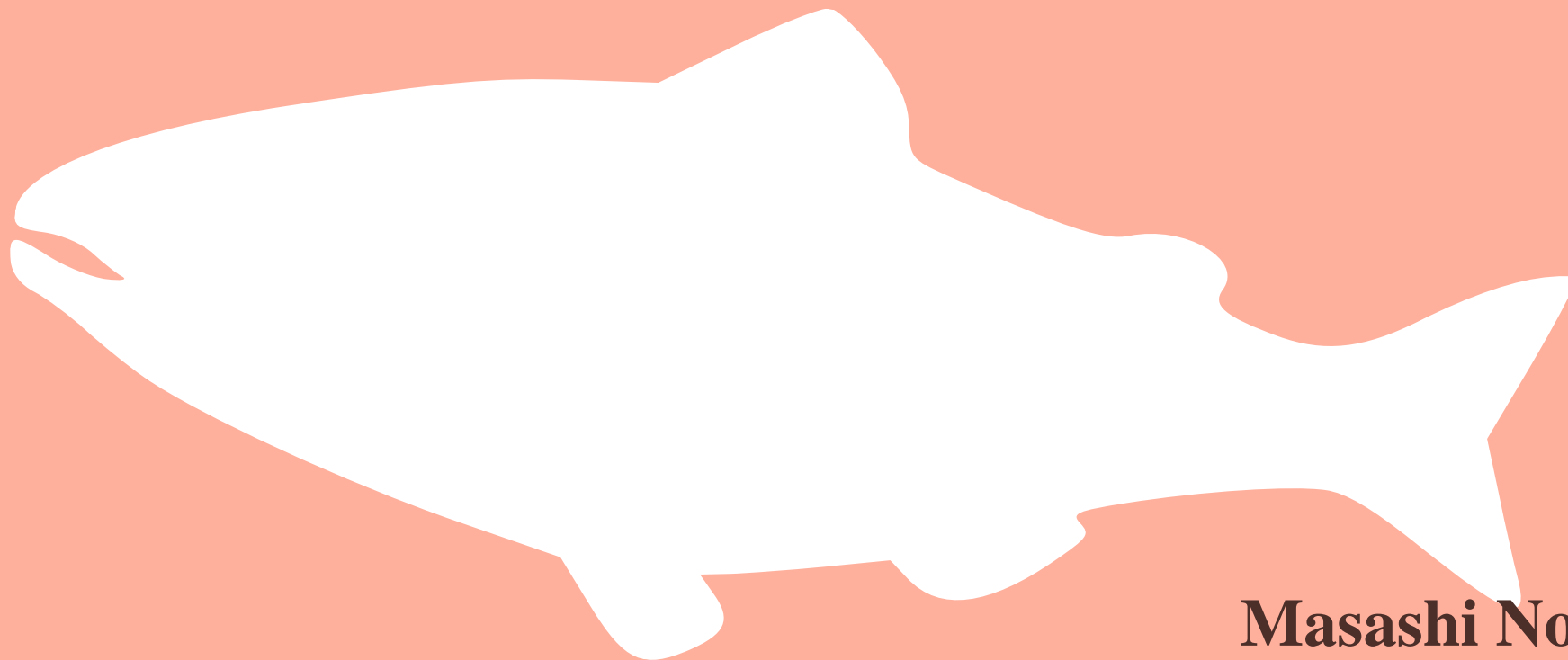


How to Use SALMON-1: Isolated Systems

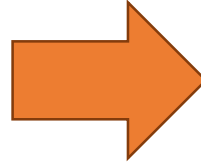
Overview



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Flowchart and equations for isolated systems

GS (Ground State) calculation
(determination of initial states)



RT (Real-time) calculation
(propagation of states)

- Ground state calculation

$$\left\{ -\frac{1}{2} \nabla^2 + V_{ion} + V_H + V_{xc} \right\} \psi_n(\mathbf{r}) = \epsilon_n \psi_n(\mathbf{r})$$

ψ_n : Kohn-Sham orbital

V_H : Hartree potential

ϵ_n : 1-particle energy

V_{xc} : Exchange-correlation potential

V_{ion} : Electron-nuclear interaction potential

- Time evolution calculation

$$i\hbar \frac{\partial}{\partial t} \psi_n(\mathbf{r}, t) = \left\{ -\frac{1}{2} \nabla^2 + V_{ext}(\mathbf{r}, t) + V_{ion} + V_H + V_{xc} \right\} \psi_n(\mathbf{r}, t)$$

$V_{ext}(\mathbf{r}, t)$: External scalar potential

Optical response calculation

- Impulsive force

$$V_{ext}(t) = V_0 \delta(t)$$

- Dipole moment

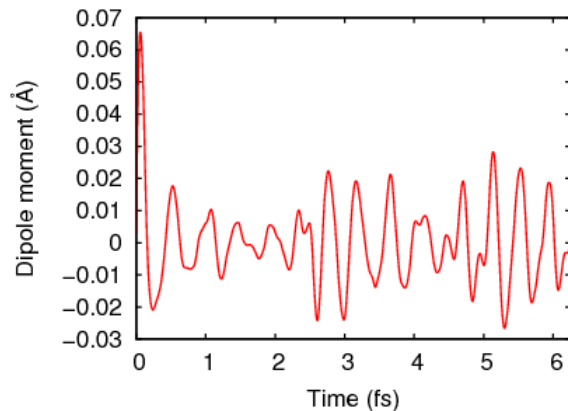
$$d(t) = -e \int r_v (\rho(\mathbf{r}, t) - \rho(\mathbf{r}, 0)) d\mathbf{r}$$

- Oscillator strength function

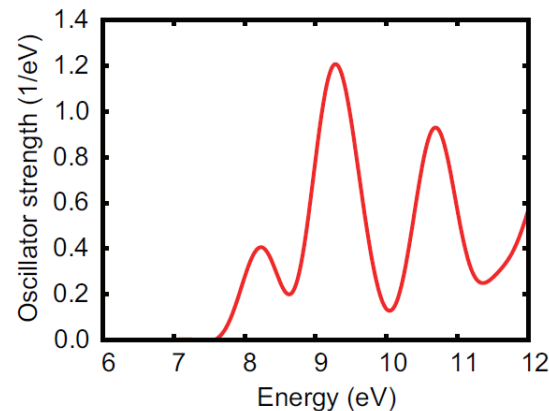
$$\frac{df_v(E)}{dE} = \frac{2mE}{\pi\hbar^3} \text{Im} \int_0^T f\left(\frac{t}{T}\right) d(t) e^{iEt/\hbar} dt$$

C₂H₂ molecule

- Dipole moment



- Oscillator strength function



Pulse calculation

- External field

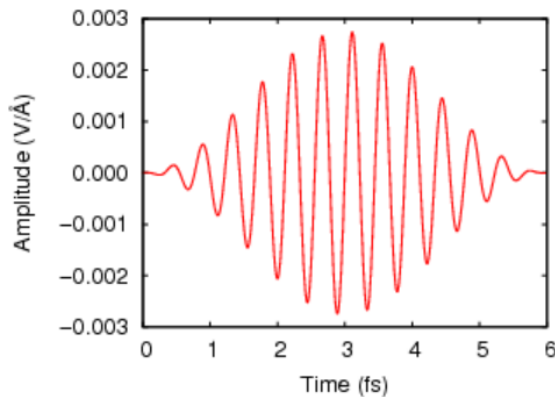
$$V_{ext}(t) = E_0 \cos^2\left(\frac{\pi(t-t_0)}{T}\right) \cos(\omega t + \phi)$$

- Dipole moment

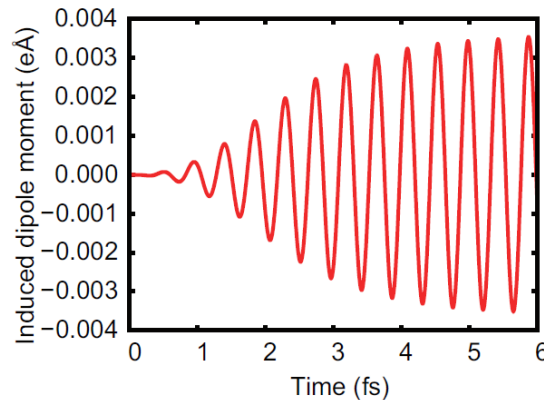
$$d(t) = -e \int r_v (\rho(\mathbf{r}, t) - \rho(\mathbf{r}, 0)) d\mathbf{r}$$

The C₂H₂ molecule under a laser pulse ($\omega = 9.28\text{eV}$)

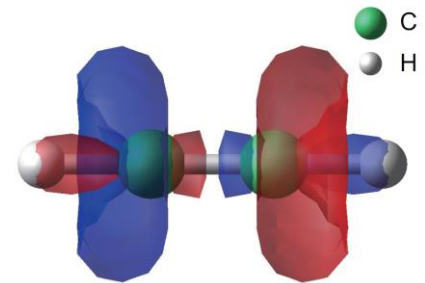
- Shape of pulse



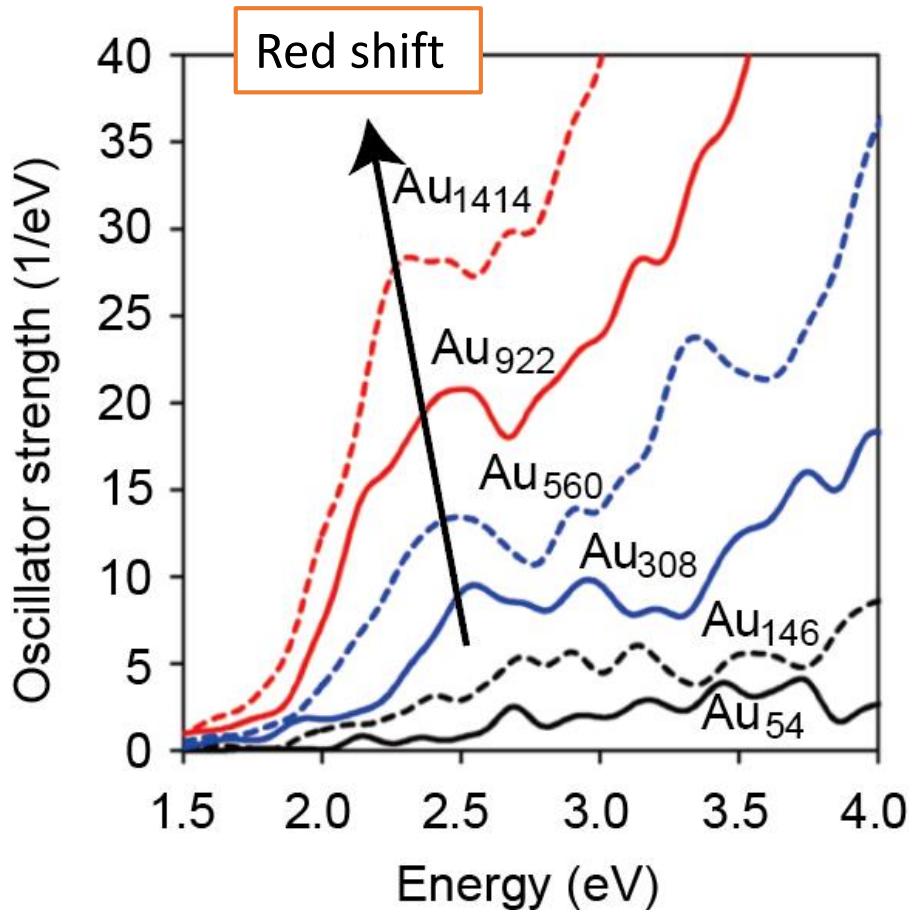
- Dipole moment



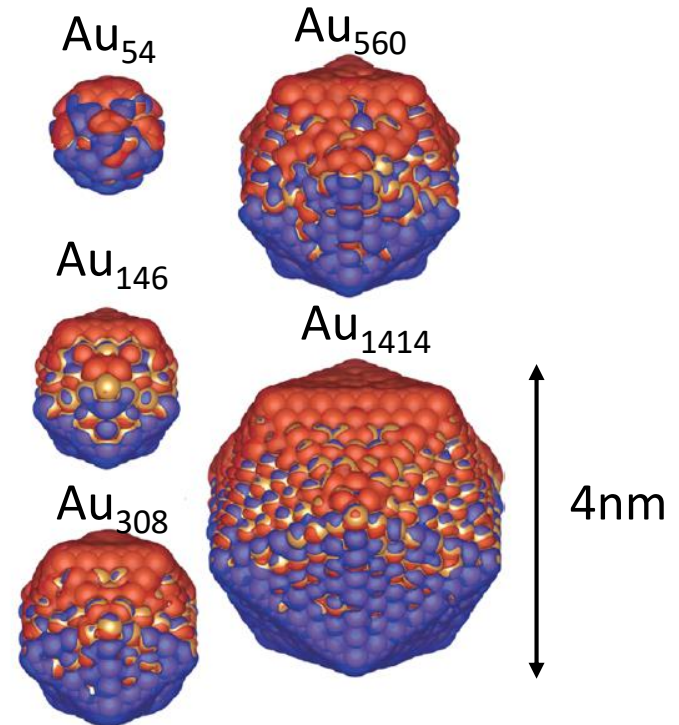
- Difference of electron density



Applications (1): gold nanocluster



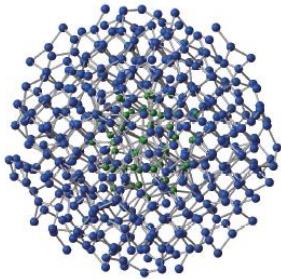
Difference of electron density



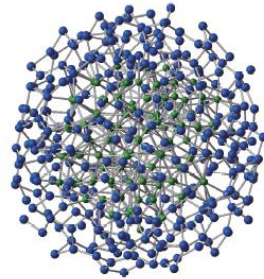
Localized surface plasmon resonance gradually grows with increasing cluster size.

Applications (2): coreshell structures

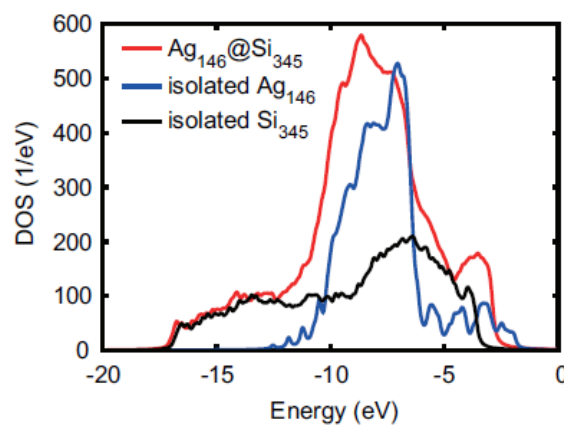
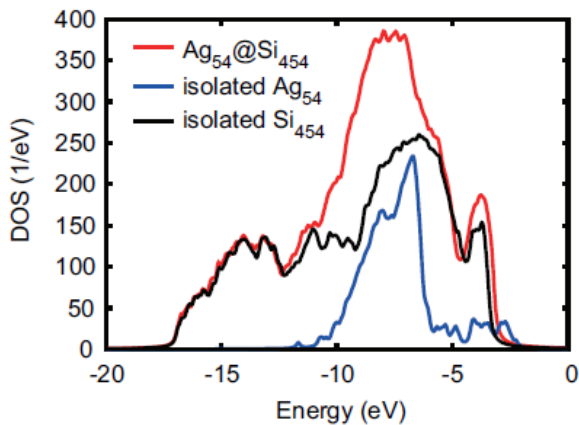
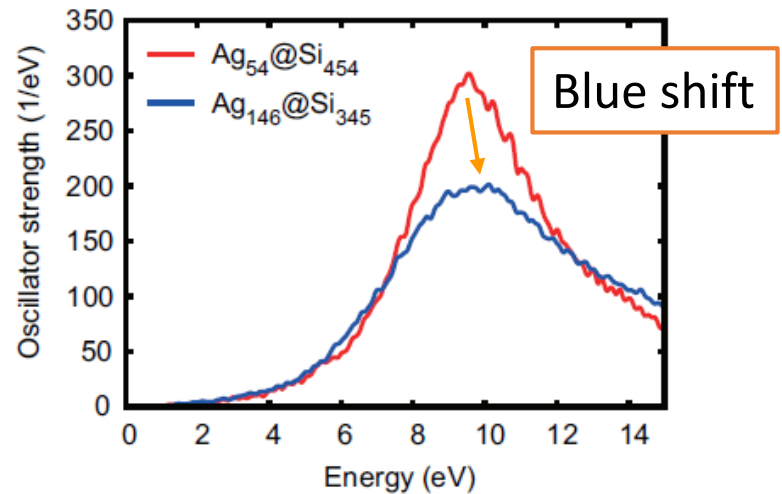
$\text{Ag}_{54}@\text{Si}_{454}$



$\text{Ag}_{146}@\text{Si}_{345}$



Diameter: 2.5nm



DOS of coreshell structures differs